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1 IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Marc David Levenson et. al.

March 8, 2005

Serial No.: 10/775313

Group No.:

Filed: February 10, 2004

Examiner:

6 For: Photosensitive material for immersion photolithography

Commissioner of Patents and Trademarks

Washington, D.C. 20231

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PETITION TO REVIVE AN UNINTENTIONALLY ABANDONED APPLICATION

16 The Applicant herewith petitions the Commissioner of Patents and Trademarks to revive the above identified patent application under rule 1.137(b). The entire delay in providing the required notice of rescission from the due date of the notice of rescission until the filing of a grantable petition pursuant to rule 1.137(b) was unintentional.

21 The application became abandoned on Aug. 23, 2004, when applicant failed to submit a rescission of previous nonpublication request (35 U.S.C. 122(b)(2)(b)(ii)) and Notice of foreign filing (35 U.S.C. 122(b)(2)(b)(iii)). Applicant filed a PCT application in US receiving office on July 8, 2004 (PCT/US 0422592) wherein the invention disclosed in the above identified patent application was disclosed.

26 A petition fee of \$750 is required. Please charge deposit account number 08/2240. Any deficiency or overpayment with regard to this communication should be charged or credited to deposit account number 08/2240.

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Docket No 903-0068 serial No. 10/775313 Inventor Marc David Levenson, , , ,
Photosensitive material for immersion photolithography-Filing date February 10, 2004,

PAGE 1/4 * RCVD AT 3/8/2005 3:07:57 PM [Eastern Standard Time] * SVR:USPTO-EFXXP-1/6 * DNIS:8729306 * CSID:9147624126 * DURATION (mm:ss):01:32